

Lawrence Berkeley National Laboratory

Recent Work

Title

STABILITY OF THE Si LATTICE: ELECTRON-PHONON INTERACTIONS AND SUPERCONDUCTIVITY IN HEXAGONAL Si

Permalink

<https://escholarship.org/uc/item/25j9b4td>

Author

Erskine, D.

Publication Date

1986-08-01



Lawrence Berkeley Laboratory

UNIVERSITY OF CALIFORNIA

RECEIVED
LAWRENCE
BERKELEY LABORATORY

Materials & Molecular Research Division

FEB 9 1987

LIBRARY AND
DOCUMENTS SECTION

Presented at the 18th International Conference on
the Physics of Semiconductors, Stockholm, Sweden,
August 11-15, 1986

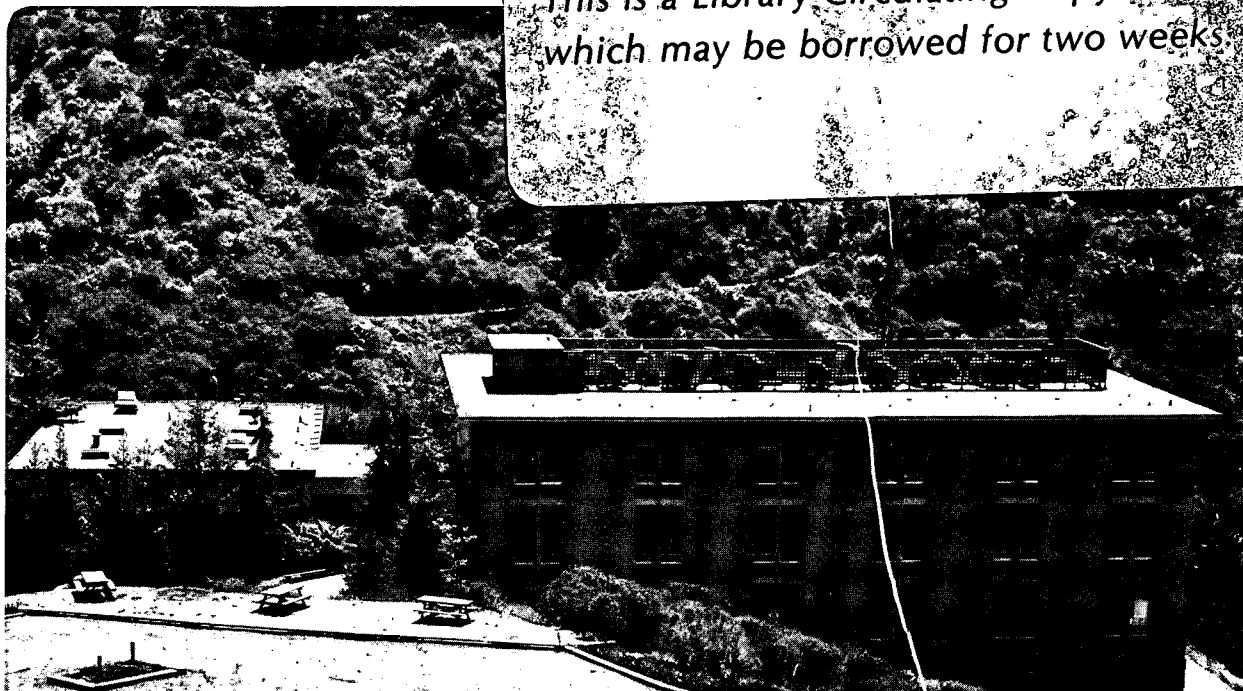
STABILITY OF THE Si LATTICE:
ELECTRON-PHONON INTERACTIONS AND
SUPERCONDUCTIVITY IN HEXAGONAL Si

D. Erskine, P.Y. Yu, K.J. Chang, and M.L. Cohen

August 1986

TWO-WEEK LOAN COPY

*This is a Library Circulating Copy
which may be borrowed for two weeks.*



LBL-21990
c.2

DISCLAIMER

This document was prepared as an account of work sponsored by the United States Government. While this document is believed to contain correct information, neither the United States Government nor any agency thereof, nor the Regents of the University of California, nor any of their employees, makes any warranty, express or implied, or assumes any legal responsibility for the accuracy, completeness, or usefulness of any information, apparatus, product, or process disclosed, or represents that its use would not infringe privately owned rights. Reference herein to any specific commercial product, process, or service by its trade name, trademark, manufacturer, or otherwise, does not necessarily constitute or imply its endorsement, recommendation, or favoring by the United States Government or any agency thereof, or the Regents of the University of California. The views and opinions of authors expressed herein do not necessarily state or reflect those of the United States Government or any agency thereof or the Regents of the University of California.

STABILITY OF THE Si LATTICE: ELECTRON-PHONON INTERACTIONS AND SUPERCONDUCTIVITY IN HEXAGONAL Si

David Erskine, Peter Y. Yu, K.J. Chang and Marvin L. Cohen

MMRD, Lawrence Berkeley Laboratory and Department of Physics,
University of California, Berkeley, CA. 94720, U.S.A.

ABSTRACT

Using ab initio pseudopotentials the properties of electrons, phonons and electron-phonon interactions in highly compressed Si have been computed. In particular, the hexagonal phases have been predicted to be superconducting by this calculation. The superconducting transition temperature for hexagonal Si has been measured for pressures between 16-45 GPa and compared to the theoretical value.

1. INTRODUCTION

The crystal structure of silicon undergoes a progression of transformations as it is compressed hydrostatically to pressures >10 GPa. From x-ray diffraction studies^[1], this progression has been determined to be: diamond → beta-tin → primitive hexagonal(PH) → hexagonal close packed(HCP), occurring approximately at the pressures 10, 16, and 40 GPa respectively (see Fig.1).

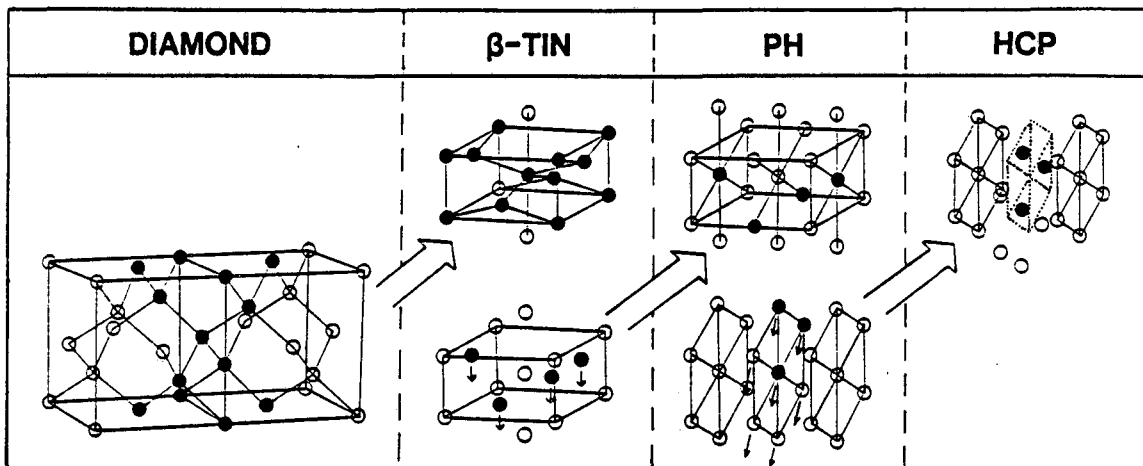


Fig.1. Progression of crystal structures for Si as it is compressed. Solid circles are meant to represent same atoms during transformation between structures.

The first of these phases is semiconducting, the latter ones are metallic. Furthermore, these metallic phases have been found to be superconducting. Because of the great sensitivity of the superconducting transition temperature (T_c) on the detailed properties of the electrons, phonons, and electron-phonon interaction, a study of the pressure (P) dependence of T_c leads to a better understanding of the Si lattice and its bonding.

2. THEORY

Using ab initio pseudopotentials and the frozen phonon approximation, the properties of electrons, phonons and the electron-phonon interaction λ in hexagonal (PH and HCP) Si have been calculated^[2,3]. We found that unlike graphite, the bonding between the hexagonal planes of Si atoms is stronger than within the planes. Furthermore, pressure induces additional charge transfer from within the planes to the interplanar region. This charge transfer softens the transverse acoustic (TA) phonon propagating along the c -axis and enhances its electron-phonon interaction. This is shown more clearly from the P dependence of λ for phonons propagating along three directions. The softening of the TA phonon along the [001] direction is responsible for the increase in the corresponding λ near 40 GPa. Similarly, another soft phonon mode along the [011] direction is responsible for the large λ near 20GPa. Based on these theoretical values of λ we expect that T_c , which depends on λ averaged over the entire Brillion zone, to first decrease rapidly with P , reach a minimum above 30GPa and then increase before 40GPa.

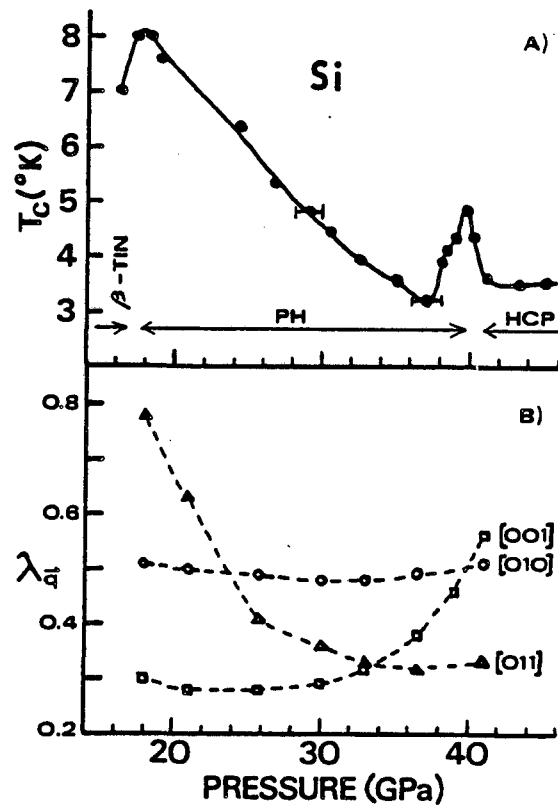
3. EXPERIMENTAL

To verify these predictions we have measured the pressure dependence of T_c in Si between 16-46 GPa using a diamond anvil cell (DAC). A new technique has been developed to introduce wires into the DAC for four-probe resistance measurements under quasi-hydrostatic conditions. The sample was a single crystal of Si doped with $3 \times 10^{14} \text{ cm}^{-3}$ of phosphorus, $25 \times 25 \times 75 \text{ (micron)}^3$ in size, surrounded by a soft

powder and pressed against two half-loops of fine copper wire. A standard steel gasketing arrangement is used, except that Al_2O_3 powder is used to insulate the wires from the gasket. The sample pressure is determined in situ by measuring the shift in the fluorescence wavelength of tiny ruby chips placed adjacent to the sample.

The experimental results are shown in Fig.2a. In agreement with theory, T_c first decreases with pressure above 16 GPa and reaches a minimum value of 3.3 K around 37 GPa before increasing sharply to 4.9 K. The initial decrease agrees with the experimental results of Chang et al. [3]. Around 40 GPa T_c drops suddenly back to 3.5 K, presumably due to a transition into the HCP phase. In this phase T_c increases very slowly with pressure in agreement with the theoretical predictions.

Fig.2 a) Measured superconducting transition temperature T_c for Si versus pressure. b) Calculated pressure dependent electron-phonon λ interaction strength for three phonon wavevectors.



4. DISCUSSION

Overall the experimental P dependence of T_c agrees with the theoretical prediction. A quantitative comparison between theory and experiment is not meaningful at present because λ has been calculated for phonons propagating along three directions only. Also in the present calculation λ is found to be divergent at the beta-tin \rightarrow PH transition because the frequency of the phonon in the [011] direction decreases to zero at the phase transition. Thus the present theory breaks down when a phonon mode becomes completely soft.

An additional phase transition into a new intermediated phase (Si VI) between PH and HCP has been observed by Olijnyk et al.^[1] in Si between 36 and 40 GPa, (although this phase has not been seen by Spain and coworker^[4]). The x-ray diffraction pattern of Si VI can be explained by a double HCP (DHCP) crystal structure, (stacking order ABACABAC...). However a total energy calculation performed for DH Si shows that this phase is metastable. If further x-ray diffraction studies confirm the existence of Si VI, then the increase in T_c between 37 and 40 GPa could be associated with this phase.

5. CONCLUSION

In conclusion, we have investigated both theoretically and experimentally superconductivity of highly compressed Si in its hexagonal phases. The measured pressure dependence of T_c can in large part be explained by the effect of soft phonon modes which accompany structural phase transitions.

6. REFERENCES

1. H. Olijnyk, S. Sikka and W. Holzappel, Phys. Lett. 103A, 137 (1984).
2. M. Dacorogna, K.J.Chang and M.L.Cohen, Phys. Rev. B32, 1853 (1985).
3. K.J. Chang, M. Dacorogna, M.L. Cohen, J. Mignot, and G. Martinez, Phys. Rev. Lett. 54, 2375 (1985).
4. I.L. Spain (private communication).

7. ACKNOWLEDGEMENTS

We are grateful to Dr. Gerard Martinez for his generous assistance and advice in this project and to Tom Pederson for his valuable technical assistance. This research was supported by the Director, Office of Energy Research, Office of Basic Energy Sciences, Materials Sciences Division of the U.S. Department of Energy under Contract Number DE-AC03-76SF00098 and by the National Science Foundation under Grant No. DMR-83-19024. Computer time was provided by the Office of Energy Research of the U.S. Department of Energy.

This report was done with support from the Department of Energy. Any conclusions or opinions expressed in this report represent solely those of the author(s) and not necessarily those of The Regents of the University of California, the Lawrence Berkeley Laboratory or the Department of Energy.

Reference to a company or product name does not imply approval or recommendation of the product by the University of California or the U.S. Department of Energy to the exclusion of others that may be suitable.

*LAWRENCE BERKELEY LABORATORY
TECHNICAL INFORMATION DEPARTMENT
UNIVERSITY OF CALIFORNIA
BERKELEY, CALIFORNIA 94720*